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William K allow

William R. Allen, Ph.D., Reg. No. 48,389

15 Mars 2002

Date

PATENT

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Applicants:

Louis A. Rigali et al.

Serial No:

09/829,305

Filed:

April 9, 2001

Group Art Unit:

1763

Examiner:

Unknown

Title:

HIGH THROUGHPUT PLASMA TREATMENT SYSTEM

Atty Docket:

NOR-953B

Cincinnati, Ohio 45202

March 15, 2002

Assistant Commissioner for Patents Washington, DC 20231

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

In accordance with the duty of candor and good faith imposed by 37 C.F.R. §1.56, and means of complying therewith according to 37 C.F.R. §\$1.97 and 1.98, the references listed on the attached Form PTO-1449 are called to the attention of the United States Patent and Trademark Office in connection with the above-identified patent application. Copies of the cited references are enclosed herewith and Applicants request that the Examiner

consider the cited references and make an independent evaluation of their materiality.

It is submitted that none of the cited references of record or now cited, either alone or in combination, disclose or render obvious that subject matter claimed in the present application.

Applicants do not believe that any fees are due in connection with this response. However, if such petition is due or any other fees are necessary, the Commissioner may consider this to be a request for such and charge any necessary fees to deposit account 23-3000.

Respectfully submitted,

WOOD, HERRON & EVANS, L.L.P.

BY William R. Allen, Ph.D.

Reg. No. 36,330

2700 Carew Tower Cincinnati, OH 45202 (513) 241-2324

of SUBSTITUTE FORM PTO-1449 U.S. DEPARTMENT OF COMMERCE ATTY, DOCKET NO. U.S. DEPARTMENT OF COMMERCE PATENT AND PRADEMARK OFFICE 29,300 (19,4) 2002 TOUPY 3002 NOR/953B (MODIFIED) INFORMATION DISCLOSURE **APPLICANT** STATEMENT BY APPLICANT MAR 2 2 2002 Louis A. Rigali et al. **FILING DATE** (Use several sheets if necessary) (37 CFR 1.98(b)) April 9, 2001 U.S. PATENT DOCUMENTS FILING DATE **EXAMINER** ISSUE IF APPROPRIATE PATENT NUMBER **CLASS SUBCLASS** INITIAL DATE **PATENTEE** 3 2 4 6 0 12/27/66 Charschan et al. 204 298 10/7/63 A.A 3 6 9 3 2/15/72 Shrader 118 49 11/25/70 A.B 4 1 A.C 2 8 5 2 8 7/14/81 Kuehnle et al. 204 298 10/9/79 A.D 4 3 3 6 4 3 8 6/22/82 Uehara et al. 219 121PG 9/16/80 4 4 8 6 3 9 12/6/83 Wills et al. 118 50 5/19/81 A.E 1 A.F 5 5 0 2 3 9 10/29/85 Uehara et al. 219 121PG 9/27/82 4 0 2 9/13/88 118 686 2/3/87 A.G 7 Ebata et al. A.H 4 8 1 6 6 3 8 3/28/89 Ukai et al. 219 121.43 10/20/87 0 0 6/20/89 Schumacher, III 156 643 12/29/87 A.I 4 8 4 7 2 5 0 3 0 0 5 6 7/9/91 414 749 7/23/90 A.J Kitayama et al. A.K 5 0 8 6 2 9 2/11/92 Katagiri 118 729 6/13/89 FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS TRANSLATION DOCUMENT **PUBLICATION** COUNTRY OR NUMBER PATENT OFFICE CLASS **SUBCLASS** (YES/NO) DATE DE 3935002 4/1991 Abstract Only A.L Germany A.M 59-164696 9/1984 Japan Abstract Only 04-123430 4/1992 Abstract Only A.N Japan Abstract Only A.O 03-023137 1/1991 Japan Abstract Only A.P 11/1992 04-311044 Japan A.Q 03-159143 7-1991 Abstract Only Japan OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication) A.R Materials Research Corporation, 1.12 Inline production magnetron sputtering, Journal Article, 3 pages A.S Von Dr.-Ing M. Nowottnick, Fraunhofer-Einrichtung fur Zuverlassigkeit und Mikrointegration (IZM), Berlin, Plasmabehandlung als umweltfreundliche Alternative in der Leiterplattenfertigung, Galvanotechnik D-88348 Saulgau 86 (1995) Nr. 4; Journal Article, 6 pages A.T DATE CONSIDERED **EXAMINER** EXAMINER: Initial if citation considered, whether or not in conformance. Draw line through citation only if not in conformance and not considered.

Include a copy of this form with next communication to applicant.

of Andrews Sheet 2 (B) U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OF ICE SUBSTITUTE FORM PTO-1449 ATTY. DOCKET NO. SERIAL NO. (MODIFIED) NOR/953B 09/829,305 INFORMATION DISCLOSURE **APPLICANT** STATEMENT BY APPLICANT Louis A. Rigali et al. (Use several sheets if necessary) **GROUP** FILING DATE (37 CFR 1.98(b)) April 9, 2001 1763 U.S. PATENT DOCUMENTS EXAMINER **ISSUE** FILING DATE INITIAL IF APPROPRIATE PATENT NUMBER DATE **PATENTEE CLASS SUBCLASS** B.A 2 2 2 5 6 3 6/1/93 Straemke 219 121.43 2/25/91 B.B 5 3 4 5 0 5 6 9/6/94 Frei et al. 219 121.59 12/12/91 4 7 B.C 5 3 3 3 7/18/95 1 Morisako 228 180.5 10/13/93 B.D 5 4 8 0 0 5 2 1/2/96 Furr et al. 216 71 10/22/93 B.E 5 4 9 2 2 6 5 2/20/96 Wandke 228 205 12/20/94 B.F 5 5 2 4 5 5 9 8/6/96 Kawakami et al. 216 67 2/14/94 B.G 5 5 7 6 6 2 9 11/19/96 Turner et al. 324 709 10/24/94 В.Н 5 6 0 9 2 9 0 3/11/97 Bobbio et al. 228 206 4/20/95 5 B.I 6 3 4 7 6 5 6/3/97 Miyoshi 414 786 6/7/95 B.J 5 0 7 8 1/13/98 7 4 5 Rolfson et al. 156 643.1 12/20/95 B.K 5 7 2 6 10/26/99 9 3 Haji 156 345 2/6/98 FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS DOCUMENT **PUBLICATION** COUNTRY OR **TRANSLATION** NUMBER **SUBCLASS** DATE PATENT OFFICE **CLASS** (YES/NO) B.L B.M B.N B.O B.P B.Q

OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)

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